Authors

Shakir A. Abbas

Systems Development Division, Poughkeepsie, New York

B.Sc. in Electrical Engineering, 1949, Birmingham University, England; M.S. and Ph.D. in Electrical Engineering, 1955 and 1958, Carnegie Institute of Technology, Pittsburgh. Prior to joining IBM, he taught in Baghdad University and South Dakota School of Mines and Technology. Joined IBM at Poughkeepsie in 1964 and is presently working on capacitor read only stores. Member, ASEE, IEEE, Sigma Xi.

Somanath Dash

Components Division, East Fishkill, New York

B. Tech.(Hons.) in Metallurical Engineering, 1959, Indian Institute of Technology; M.S., 1962, and Ph.D., 1964, in Metallurgical Engineering, University of Pennsylvania. Joined IBM in 1960 at Poughkeepsie. Past research includes work on diffusionless solid-state phase transformations and annealing twins in metals. Currently at the laboratories in East Fishkill where he is studying diffusion-induced defects in semiconductors and the structure of thin films. Member, RESA and AIME.

Pieter Geldermans

Systems Development Division, Poughkeepsie, New York

Degree in Chemistry obtained in the Netherlands. Previously employed by N. V. Philips in the Netherlands and Ferroxcube, Saugerties, New York. Joined IBM in 1961 at Poughkeepsie to work on ferrite materials. Is presently manager of an advanced memory technology group working in the area of thin magnetic films. Member, Electrochemical Society.

Madhukar L. Joshi

Components Division, East Fishkill, New York

B.E. in Metallurgical Engineering, 1952, Poona University; B.E. in Electrical Engineering, 1955, Gujarath University; D. Eng. in Metallurgy, 1964, Yale University. Has worked as a junior research officer at the Atomic Energy Establishment in Bombay, India. Joined IBM in 1963 at Poughkeepsie to work in the area of diffusion-induced defect structure in silicon. Continues his study of diffusion in silicon at the laboratories in East Fishkill. Member, AIME and Sigma Xi.

David P. Kennedy

Components Division, East Fishkill, New York

Member of Radiation Laboratory, MIT, 1940-42, engaged in the design of radar equipment. From 1942-58 was employed by Raytheon Manufacturing Company to work in the fields of microwave tubes, microwave communication systems, and semiconductor devices. Instructed at the Graduate School of Engineering, Northeastern University, 1953-58. Joined the IBM Development Laboratory, Data Systems

Division, Poughkeepsie, in 1958 as an Advisory Physicist in the mathematical analysis of boundary value problems relating to the design and development of semiconductor devices. Is currently a Senior Physicist and Manager of Mathematical Analysis, Semiconductor Device Theory at the East Fishkill laboratory. Member, American Physical Society.

H. Frederick Koehler

Systems Development Division, Poughkeepsie, New York

B.S., 1957, United States Military Academy; M.S.E.E., 1963, Syracuse University. Joined IBM in 1960 at Poughkeepsie to work in manufacturing engineering. Transferred to the Poughkeepsie Product Development Laboratory, Exploratory Memory Development in 1962. Worked in exploratory memory development on the chain store program from 1962 to 1964. Currently a staff engineer in a memory technology department working on memory device evaluation. On the faculty of Marist College, Department of Physics (evening division). Member, IEEE.

Thomas C. Kwei

Systems Development Division, Poughkeepsie, New York B.S.E.E., 1958; M.S.E.E., 1959, Yale University. Joined IBM in 1959 at Poughkeepsie and since has been engaged in memory development work. Currently engaged in the design and development of a monolithic store. Member, IEEE, Tau Beta Pi.

Hans-Otto Leilich

Systems Development Division, Poughkeepsie, New York

Diplom-Ingenieur (Electrical Engineering) 1952, Dr. -Ing., 1956, Technische Hochschule, Munich, Germany. Developed magnetic drum store for PERM at T. H. Munich. Worked on development of TR4-computer with Telefunken, Backnang, Germany. Joined IBM at Poughkeepsie in 1962. Worked on various film and ferrite memories and devices. He is presently a manager in advanced memory development. Member, Verein Deutscher Elektrotechniker, Nachrichtentechnische Gesellschaft, RESA; Senior Member, IEFE.

James C. McGroddy

Thomas J. Watson Research Center, Yorktown Heights, New York

B.S. in Physics, 1958, St. Joseph's College, Philadelphia; Ph.D. in Physics, 1964, University of Maryland. As a graduate student, did experimental research on the magneto-optical properties of non-ferromagnetic metals and alloys. Remained at Maryland for a year after obtaining Ph.D., conducting theoretical studies on helicons in metals. Joined IBM at Yorktown Heights in 1965 and has since been studying transport in semiconductors in strong electric fields. Member, American Physical Society, Sigma Xi and IEEE.

Marshall I. Nathan

Thomas J. Watson Research Center, Yorktown Heights, New York

B.S. in Physics, 1954, Massachusetts Institute of Technology; M.A. in Physics, 1956; Ph.D. in Applied Physics, 1958, Harvard University. Joined IBM in 1958 and currently manages a semiconductor research group at the Research Center. Member of Sigma Xi, IEEE and a Fellow of the American Physical Society.

Redmond R. O'Brien

Components Division, East Fishkill, New York

B.S. in Mathematics, 1953; M.S. in Mathematics, 1954, and Ph.D. in Mathematics, 1957, Massachusetts Institute of Technology. Joined Sylvania Electric in 1958 as a member of the Operations Research and Mathematical Analysis Department of the Applied Research Laboratory. Worked on communication and detection problems on noisy environments. Joined IBM in 1960, to work on the theoretical analysis of semiconductor devices and associated computational problems. Member, Sigma Xi, American Mathematical Society, Mathematical Association of America, and American Statistical Association.

Wilfred Palmer

Center for Naval Analyses, Arlington, Virginia

B.A. in Physics, 1952, M.A. in Physics, 1953, Rice University; Ph.D. in Physics, 1955, University of Texas. Prior to joining IBM he was a Research Associate in the Department of Physics at the University of Illinois. Joined IBM in 1958 at the Thomas J. Watson Research Center to work in the magnetic materials section. Presently employed by the Center for Naval Analyses. Member, American Physical Society and Sigma Xi.

Donald A. Quarles, Jr.

Thomas J. Watson Research Center, Yorktown Heights, New York

B.S., 1943, M.A., 1948, both at Yale University; Ph.D., 1964, New York University; all in Mathematics. Had summer job with Pure Science Department of IBM in 1948, working with the Selective Sequence Electronic Calculator. Began permanent work with IBM in 1949 and is presently with the mathematical science department at the Research Center. Current projects include work on the nonlinear

differential equations for the electrical and magnetic properties of thin-film memory, and for thermal convection in fluids, and on biomathematical models. Member, AMS, MAA, SIAM.

Richard H. Robinson

Systems Development Division, Poughkeepsie, New York B.E.E. 1960, Syracuse University. Joined IBM in 1960 at Poughkeepsie to work on device evaluation of chain-store memory elements. Has worked in the area of control memory, design and evaluation and is presently working on an advanced control storage system. Member, Tau Beta Pi and Eta Kappa Nu.

Terrence R. Scott

Systems Development Division, Poughkeepsie, New York B.S.E.E., 1957, Marquette University; M.S.E.E., 1966, Syracuse University. Joined IBM in 1957 at Poughkeepsie working in the field of memory design. Now engaged in analyses of various modes of noise propagation in ferrite core memories. Member, IEEE.

Kurt Spielberg

New York Scientific Center, Data Processing Division, New York

B.S. in Physics, 1951, City College of New York; Ph.D. in Physics, 1954, University of Vienna; Teaching certificate, Mathematics, Physics, 1955, University of Vienna; Assistant Professor, Physics, City College of New York, 1956-1961. Joined IBM in 1960, Mathematics and Applications Department, New York. Worked in hydrodynamics, approximation of functions, weather forecasting, mathematical programming. Member, Phi Beta Kappa, ACM, ORSA.

Ralph A. Willoughby

Thomas J. Watson Research Center, Yorktown Heights, New York

A.B. in Mathematics, 1947, Ph.D. in Mathematics, 1951, University of California at Berkeley. Joined IBM in 1957 and has worked in the fields of applied mathematics and numerical analysis. Member, American Mathematical Society, Association for Computing Machinery, Society for Industrial and Applied Mathematics, Pi Mu Epsilon, Sigma Xi, and Phi Beta Kappa.

Contents of previous issue

	Vol. 11, No. 2	
	• Papers on Difference Equations:	
	Foreword	213
130	On the Partial Difference Equations of Mathematical Physics by R. Courant, K. Friedrichs, and H. Lewy	215
148	On Difference Methods for Parabolic Equations and Alternating-Direction Implicit Methods for Elliptic Equations by O. B. Widlund 2 Elliptic Equations	
153		235
		239
162 169		244
179		
189		
	148 153 162 169	• Papers on Difference Equations: Foreword On the Partial Difference Equations of Mathematical Physics by R. Courant, K. Friedrichs, and H. Lewy Hyperbolic Difference Equations: A Review of the Courant, Friedrichs, Lewy Paper in the Light of Recent Developments by P. D. Lax On Difference Methods for Parabolic Equations and Alternating-Direction Implicit Methods for Elliptic Equations by O. B. Widlund 162 Elliptic Equations by S. V. Parter



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